

# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

6762-10

Application Number

Applicant(s)

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Filing Date

February 2, 2000

Group Art Unit

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
TJH		5,900,623	5/4/1999	Tsang et al.			
TJH		09/103,959	6/24/1998				

36625 U.S. PTO  
09/497051  
02/02/00

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER

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DATE CONSIDERED

1/12/2004

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